

APPLICANT'S ART CITATION (Use several sheets if necessary)		Application 10/613,574		OFGS File No. P/2850-79			
		Applicant Takeshi OOTSUKA					
		Filing Date July 9, 2003		Group Art Unit			
U.S. PATENT DOCUMENTS							
Examiner Initial	Document Number	Date MM-YYYY	Name	Class	Sub-class	Filing Date If Appropriate	
YC	US-2003/0089687	05-2003	Maki				
YC	US-2002/0006678	01-2002	Inazumachi, et al.				
YC	US-5,688,331	11-1997	Aruga, et al.				
/	US-	/	/				
/	US-	/	/				
FOREIGN PATENT DOCUMENTS							
	Document Number	Date MM-YYYY	Country	Class	Sub-class	Translation	
						Yes	No
YC	2001-287982	10-2001	Japan				X
YC	2003-152064	05-2003	Japan				X
YC	7-153706	06-1995	Japan				X
YC	JP-4-3001136	10-1992	Japan				X
YC	JP-6-151044	05-1994	Japan				X
YC	JP-6-151332	05-1994	Japan				X
YC	JP-10-189696	07-1998	Japan				X
YC	2003-124296	04-2002	Japan				X
YC	JP-2001-085505	03-2001	Japan				X
YC	JP-2001-308165	02-2001	Japan				X
OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)							
YC		English translation of Abstract for Japanese Patent Application No. JP-4-3001136					
YC		English translation of Abstract for Japanese Patent Application No. JP-6-151044					
YC		English translation of Abstract for Japanese Patent Application No. JP-6-151332					
YC		English translation of Abstract for Japanese Patent Application No. JP-10-189696					
YC		English translation of Abstract for Japanese Patent Application No. 2003-124296					
YC		English translation of Abstract for Japanese Patent Application No. JP-2001-085505					
Examiner <i>[Signature]</i>		Date Considered 2/11/2004					
EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP § 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to the applicant.							